## 1 WHAT IS CLAIMED IS:

- 1 1. A whetstone pellet, which is fixed multiple on a
- 2 pedestal to form a whetstone, comprising
- 3 a columnar base body to be fixed to the pedestal, and
- a plated layer formed on a surface of the base body,
- 5 wherein said plated layer contains abrasive grains.
- 1 2. A whetstone pellet according to claim 1, wherein,
- 2 said plated layer is an amorphous plated layer.
- 1 3. A whetstone pellet according to claim 2, wherein,
- 2 said base body is made of a metal that functions as
- 3 a catalyst upon forming said amorphous plated layer.
- 1 4. Aprocess for producing a whetstone pellet, a plurality
- 2 of which is fixed on a pedestal to form a whetstone, comprising
- 3 steps of: .
- 4 preparing plural columnar base bodies to be fixed on
- 5 said pedestal, and
- 6 forming an abrasive grain layer with a plating solution
- 7 containing abrasive grains on end surfaces of the columnar
- 8 base bodies, which are opposite to the end surface to be
- 9 fixed to said pedestal.

- 1 5. A process for producing a whetstone pellet according
- 2 to claim 4, wherein,
- 3 said plural base bodies are fixed on a fixing plate,
- a catalyst layer for electroless plating is formed on
- 5 end surfaces of said base bodies opposite to end surfaces
- 6 to be fixed to said fixing plate before or after fixing said
- 7 plural base bodies on said fixing plate, and
- 8 said plural base bodies fixed on the fixing plate are
- 9 immersed in an electroless plating solution containing
- 10 abrasive grains to form abrasive grain layers on said catalyst
- 11 layers of said base bodies.
- 1 6. A process for producing a whetstone pellet according
- 2 to claim 5, wherein,
- a masking agent is applied to a surface of said fixing
- 4 plate, before immersing said plural base bodies in said
- 5 electroless plating solution, to fix the end surfaces of
- 6 said plural base bodies to said fixing plate with said masking
- 7 agent as an adhesive, and said masking agent is applied to
- 8 the surface of said plural base bodies, on which said abrasive
- 9 grain layers are not formed.
- 7. A process for producing a whetstone pellet according
- 2 to claim 4, wherein,
- 3 after forming said abrasive grain layer on each said

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- 4 base body, said abrasive grain layer is processed to
- 5 uniformize thickness of said abrasive grain layers.
- 1 8. Awhetstone having plural abrasive grain layers dotting
- 2 a pedestal, comprising:
- 3 plural columnar base bodies fixed to said pedestal,
- 4 and
- 5 abrasive grain containing-plated layers containing
- 6 abrasive grains, that function as said abrasive grain layers,
- 7 formed only on surfaces of said base bodies including end
- 8 surfaces of said base bodies.
- 1 9. A whetstone according to claim 8, wherein,
- 2 said plated layer is an amorphous plated layer.
- 1 10. A process for producing a whetstone having plural
- 2 abrasive grain layers dotting a pedestal, comprising steps
- 3 of:
- 4 preparing said pedestal and plural columnar base bodies
- 5 to be fixed on said pedestal,
- fixing said plural base bodies on a surface of said
- 7 pedestal, on which said base bodies are to be fixed, and
- forming said abrasive grain layers on at least end
- 9 surfaces of said base bodies with a plating solution
- 10 containing abrasive grains.

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- 1 11. A process for producing a whetstone according to claim
- 2 10, wherein,
- 3 after forming said abrasive grain layers on the end
- 4 surfaces of said plural base bodies, said plural abrasive
- 5 layers are processed, so that a plane shape formed by
- 6 continuation of surfaces of said plural abrasive grain layers
- 7 has an inverse shape of an objective surface to be processed.
- 1 12. A process for producing a whetstone which comprises
- 2 steps of fixing plural base bodies on a pedestal, and forming
- 3 abrasive grain layers on end surfaces of the base bodies,
- 4 comprising a step of:
- 5 processing said end surfaces of the base bodies so that
- 6 a plane shape formed by continuation of the end surfaces
- 7 of said plural base bodies fixed on said pedestal has an
- 8 inverse shape of an objective surface to be processed.
- 1 13. A process for producing an optical element, comprising
- 2 steps of:
- 3 preparing a whetstone in which base bodies are fixed
- 4 on a pedestal, and plated layers containing abrasive grains
- 5 are formed only on surfaces of the base bodies including
- 6 end surfaces of the base bodies, and
- 7 processing a rawmaterial of an optical element by using
- 8 the whetstone to form the optical element or an intermediate

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- 9 product of the optical element.
- 1 14. A process for producing an optical element according
- 2 to claim 13, wherein,
- 3 said plated layers are amorphous plated layers.
- 1 15. A process for producing an optical element according
- 2 to claim 13, wherein,
- 3 in saidprocessing step of the raw material of an optical
- 4 element, a grinding process and a polishing process, which
- 5 is to be carried out after said grinding process, are carried
- 6 out, and
- 7 in said grinding process, the raw material of an optical
- 8 element is ground by using the whetstone.
- 1 16. A process for producing an optical element according
- 2 to claim 13, wherein,
- 3 said raw material of an optical element is fluorite.
- 1 17. A process for producing a exposure apparatus equipped
- 2 with an optical system including a lens, comprising steps
- 3 of:
- 4 preparing a whetstone in which plural base bodies are
- 5 fixed on a pedestal, and plated layers containing abrasive
- 6 grains are formed only on surfaces of the base bodies

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- 7 including end surfaces of the base bodies,
- 8 processing a raw material of a lens by using the
- 9 whetstone to form the lens or an intermediate product of
- 10 the lens, and
- installing the lens obtained by processing the raw
- 12 material of a lens into the optical system.
  - 1 18. A process for producing a exposure apparatus according
  - 2 to claim 17, wherein,
  - 3 said plated layers of the whetstone are amorphous
  - 4 plated layers.
  - 1 19. A process for producing a exposure apparatus according
  - 2 to claim 17, wherein,
  - 3 said raw material of a lens is fluorite.